

Independent Control of Electron Injection and Acceleration in a Laser Plasma Accelerator







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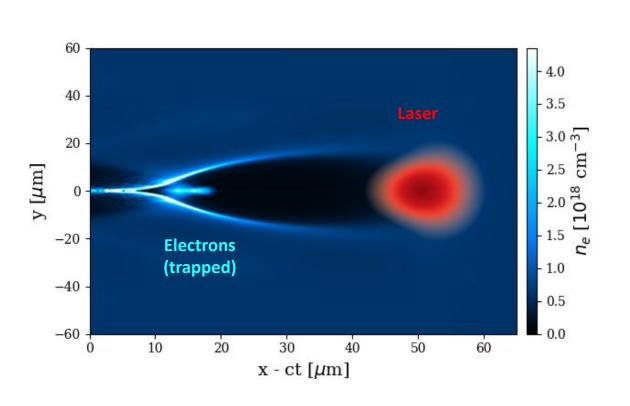
Introduction

Laser Wakefield Acceleration

Focusing ultra-intense laser pulses into a gas target to create plasma waves that trap and accelerate electrons to relativistic energies in a few millimeters.

Challenges for producing high quality electrons

- Charge conservation at higher energies
- Achieving low emittance/divergence
- Minimizing energy spread



Plasma wakefield formation by intense laser^[1]

Electron bunch properties depend mainly on the laser intensity (a_0) and plasma density profile $(n_e(x))$. Beam quality can be improved using techniques such as :

- Ionization injection \rightarrow adding high-Z impurity (e.g., N₂) \rightarrow higher charge^[2]
- Downramp injection \rightarrow controlled trapping \rightarrow lower energy spread^[3]
- Plasma lensing → reduced divergence^[4]

Although several techniques exist to address one or more of these challenges, integrating them without introducing trade-offs in stability, diagnostic accessibility, or experimental complexity remains difficult.

Compact laser-plasma accelerators have diverse applications, each with its own definition of a high-quality electron beam:

- Medical high charge and high stability
- X-ray production / FELs low emittance and energy spread
- High energy Physics / linear colliders high energy, high charge and low emittance

Thus, the characterization of beam quality depends on the intended application.

Experimental setup at the 300TW DRACO laser facility in HZDR, GermanyLaser and Plasma Diagnostics

Laser NF & FF (on-shot) Emission spectrometer High-res probe CCD

Charge calibrated lanex screens and dipole magnet

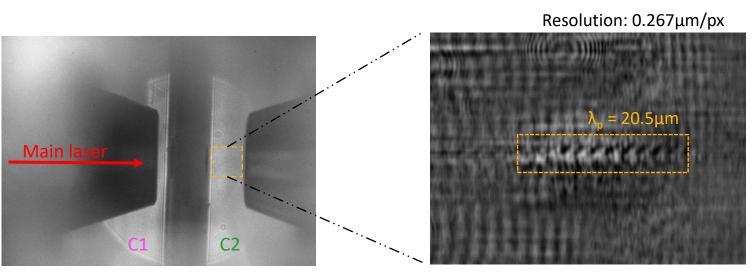
Plasma wave only visible in the

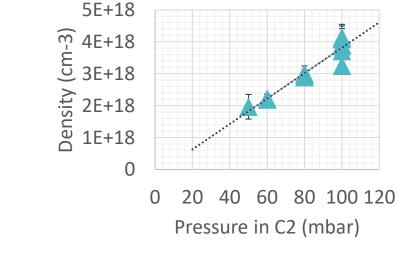
Tracks beam quality and pointing Monitors presence of N_2 leaking into C2 Measures plasma density using few cycle pulse probe shadowgraphy Beam characterization with charge and

energy distribution

Estimation of plasma density using few cycle pulsed probe shadowgraphy^[5]

Shadowgram with 5 plasma cavities



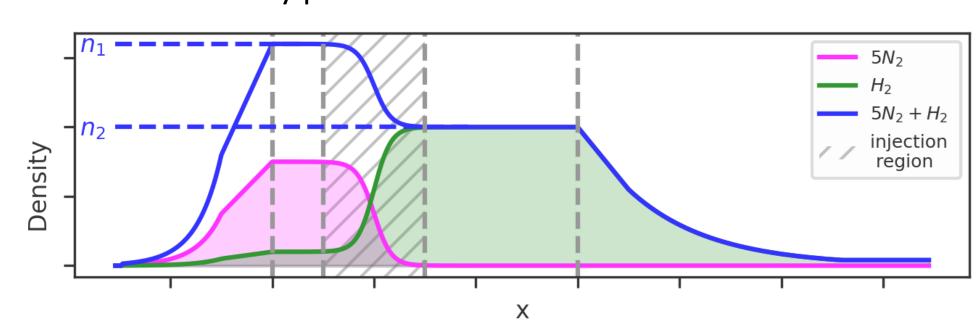


Plasma density extrapolated for low pressure cases

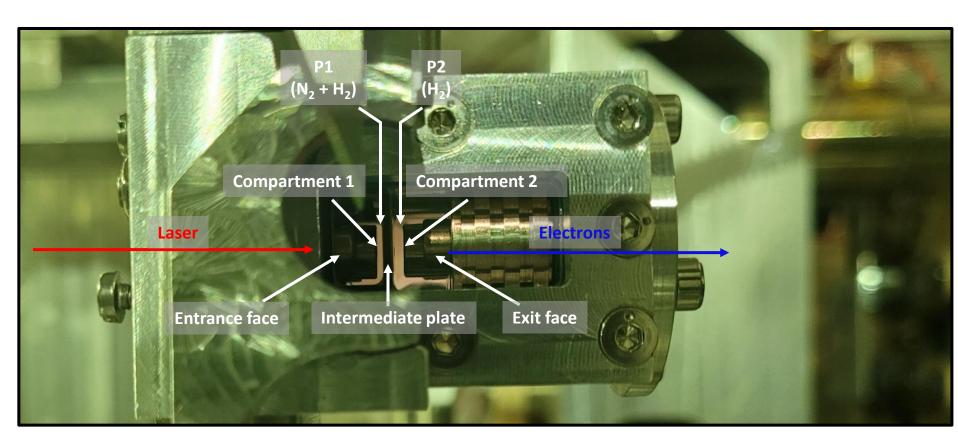
Double Compartment Gas Cell

Improved beam quality can be achieved by decoupling the injection and the acceleration mechanism.

A 2-compartment gas cell with modular design and individual gas injection system allows us to tailor the density profile.



Plasma density profile



Gas cell picture

Tunable parameters: compartment lengths, intermediate plate thickness, entry/exit diameters, nitrogen impurity level, pressure, trigger delay & window.

Tailored density profiles: enables controlled shaping of the plasma environment.

Combined techniques: ionization injection, downramp, and plasma focusing \rightarrow localised injection and acceleration to optimize beam shape while preserving charge.

Results • $P1 = P_0 \text{ mbar}$ • $P1 = 1.5 P_0 \text{ mbar}$ 600 **%** 500 200 × 200 × 200 30 Pressure in C2 (mbar) • $P1 = P_0 \text{ mbar}$ • $P1 = 1.5 P_0 \text{ mbar}$ 2D energy spectrum and lineout Q_{FWHM} is conserved at higher energies, ³⁰⁰ ⊗ 250 evidencing the role of C1 for injection and Charge 200 C2 for acceleration. 1. Peak energy increases linearly with C2 ₩ 100 50 V pressure (for both C1 settings) → tunable energy 2. FWHM charge remains constant with

Together, these results demonstrate a high quality electron source with tunable energy and charge using one single laser beam^[6].

A tunable and compact high quality e source

For external beam radiotherapy

C2 pressure → stable charge output

- High charge, variable-energy beams → VHEE source (50–250 MeV)
 For studying Ultra High Dose Rate Effects or FLASH effect
- LPAs naturally produce ultrashort electron bunches (≈ps fs)
- Extremely high peak dose-rate

References & Acknowledgements

[1] J. Derouillat et al, Comput. Phys. Comm. (2018) [2] M. Chen et al, J. Appl. Phys. (2006) [3]H.-E. Tsai et al, Phys. Plasmas (2018) [4]Y.-Y. Chang et al, Phys. Rev. Appl. (2023) [5] Susanne Schöbel et al, New J. Phys. (2022)
[6] The study of minimizing the divergence can be found in this paper: https://arxiv.org/abs/2506.18047 and at the poster of L. Steyn titled: "Enhancing electron beam quality through customized density gradients in Laser Plasma accelerators"

Pressure in C2 (mbar)

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